## **DECLARATION FOR PATENT APPLICATION**

As a below-named inventor, We hereby declare that:

My residence, post office address and citizenship are as stated below next to my name,

I believe I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed and for which a patent is sought on the invention entitled

## MULTIPLE EXPOSURE METHOD FOR FORMING PATTERNED PHOTORESIST LAYER

the specification	on of which	was Applicatio	tached hereto. filed on on Serial No. amended on ble)	_ as	
-			and understand the c nended by any amendme		
			formation which is mat Code of Federal Regul		
application(s)	for patent or interest for partial for par	inventor's ce atent on inve	under Title 35, United Sertificate listed below an entor's certificate having	nd have also iden	tified below any
Prior Foreign Application(s)			Priority Claimed		
Number	Coun	try	Day/Month/Year	(Yes)	(No)
Number	Coun	try	Day/Month/Year	(Yes)	(No)
Number	Coun	 trv	Day/Month/Year	(Yes)	(No)

I hereby claim the benefit under Title 35, United States Code, §120 of any United States application(s) listed below and, insofar as the subject matter of each of the claims of this application is not disclosed in the prior United States application in the manner provided by the first paragraph of Title 35, §112, I acknowledge the duty to disclose material information as defined in Title 37, Code of Federal Regulations, §1.56(a) which occurred between the filing date of the prior application and the national or PCT international filing date of this application:

Application Serial No.

Filing Date

Status

I hereby claim the benefit under 35 U.S.C. §119(e) of any United States provisional application(s) listed below.

**Application Number** 

Filing Date

I further declare that I do not know and do not believe that the invention claimed in this application was ever known or used by others in this country before my invention thereof, or patented or described in any printed publication in any country before my invention thereof, or more than one year prior to this application or any prior U.S. application above identified in which said invention may have been disclosed, or in public use or on sale in the United States of America for more than one year prior to this application or any prior U.S. application above identified in which said invention may have been disclosed.

## **POWER OF ATTORNEY**

And I hereby appoint as my attorneys with full power of substitution to prosecute this application and to transact all business in the United States Patent and Trademark Office connected therewith to the firm of TUNG & ASSOCIATES, including the following individual attorneys associated with the firm:

Individual Attorney

Reg. No.

Randy W. Tung

31,311

Please send all correspondence concerning this application to the following address:

**TUNG & ASSOCIATES** 

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Fax: (248) 540-4035

## 67,200-1145 2002-1332

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application and of any patent issued thereon.

Full name of first joint inventor	SHIN-RUNG LU First Middle Last
Inventor's Signature	Jane. 19. 2003
Date	June. 19. 2003
Residence	5F, No. 5, Lane 398, Sec. U. Knong Fu Rd., Hin chu, Paiwan
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Full name of second joint inventor	KUN-HONG LIN First Middle Last
Inventor's Signature	Totalism and
Date	June. 19, 2003
Residence	Taiwan, Republic of China Taiwan
Citizenship	Taiwan, Republic of China TAIWAN
Post Office Address	121 Park Ave III, Science Based Industrial Park
	Hsin-Chu Taiwan

- §1.56 Duty to disclose information material to patentability
  - (a) A patent by its very nature is affected with a public interest. The public interest is best served, and the most effective patent examination occurs when, at the time an application is being examined, the Office is aware of and evaluates the teachings of all information material to patentability. Each individual associated with the filing and prosecution of a patent application has a duty of candor and good faith in dealing with the Office, which includes a duty to disclose to the Office all information known to that individual to be material to patentability as defined in this section. The duty to disclose information exists with respect to each pending claim until the claim is canceled or withdrawn from consideration, or the application becomes abandoned. Information material to the patentability of a claim that is canceled or withdrawn from consideration need not be submitted if the information is not material to the patentability of any claim remaining under consideration in the application. There is no duty to submit information which is not material to the patentability of any existing claim. The duty to disclose all information known to be material to patentability is deemed to be satisfied if all information known to be material to patentability of any claim issued in a patent was cited by the Office or submitted to the Office in the manner prescribed by §§ 1.97(b)-(d) and 1.98. However, no patent will be granted on an application in connection with which fraud on the Office was practiced or attempted or the duty of disclosure was violated through bad faith or intentional misconduct. The Office encourages applicants to carefully examine:
  - (1) prior art cited in search reports of a foreign patent office in a counterpart application; and
  - (2) the closest information over which individuals associated with the filing or prosecution of a patent application believe any pending claim patentably defines, to make sure that any material information contained therein is disclosed to the Office.
  - (b) Under this section, information is material to patentability when it is not cumulative to information already of record or being made of record in the application, and
  - (1) It establishes, by itself or in combination with other information, a prima facie case of unpatentability of a claim; or
    - (2) It refutes, or is inconsistent with, a position the applicant takes in:
    - (i) Opposing an argument of unpatentability relied on by the Office, or
    - (ii) Asserting an argument of patentability.

A prima facie case of unpatentability is established when the information compels a conclusion that a claim is unpatentable under the preponderance of evidence, burden-of-proof standard, giving each term in the claim its broadest reasonable construction consistent with the specification, and before any consideration is given to evidence which may be submitted in an attempt to establish a contrary conclusion of patentability.

- (c) Individuals associated with the filing or prosecution of a patent application within the meaning of this section are:
  - (1) Each inventor named in the application;
  - (2) Each attorney or agent who prepares or prosecutes the application; and
- (3) Every other person who is substantively involved in the preparation or prosecution of the application and who is associated with the inventor, with the assignee or with anyone to whom there is an obligation to assign the application.
- (d) Individuals other than the attorney, agent or inventor may comply with this section by disclosing information to the attorney, agent or inventor.
  (35 U.S.C. 6, Pub. L. 97-247)
- [42 FR 5593. Jan. 28, 1977, as amended at 47 FR 21751, May 19, 1982; 48 FR 2710, Jan. 20, 1983; 49 FR 554, Jan. 4, 1984; 50 FR 5171, Feb. 6, 1985; 53 FR 47808, Nov. 28, 1988, effective Jan. 1, 1989; 57 FR 2034, January 17, 1992, effective March 6, 1992]